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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Application Serial No. 09,536,037
Filing Date March 27, 2000
Inventor Weimin Li, et al.
Assignee Micron Technology, Inc.
Group Art Unit 2822
Examiner T. Thomas
Attorney's Docket No. MI22-1398
Title: Low k Interlevel Dielectric Layer Fabrication Methods.

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

References -- See Attached Form PTO-1449

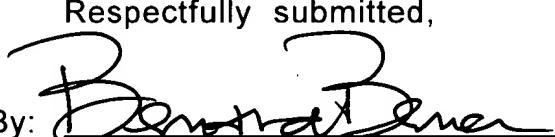
The attached form PTO-1449 is submitted in compliance with 37 CFR § 1.56. Copies of the cited prior art references are attached. No admission is made regarding whether the submitted references are prior art.

Citations of these references is respectfully requested.

Date: Aug 31, 2001

Respectfully submitted,

By:


Bernard Berman, Reg. No. 37,279
WELLS, ST. JOHN, ROBERTS,
GREGORY & MATKIN P.S.
601 W. First Avenue, Suite 1300
Spokane, WA 99201-3828
(509) 624-4276

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Inventor: Weimin Li et al.

Title: Low k Interlayer Dielectric Layer Fabrication Methods

Assignee: Micron Technology, Inc.

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INFORMATION DISCLOSURE STATEMENT

PURSUANT TO 37 C.F.R. §§1.56, 1.97 AND 1.98

In compliance with 37 C.F.R. §§1.56, 1.97 and 1.98, your attention is directed to the United States patents and other references listed on the attached Form PTO-1449. No admission is made regarding whether all the submitted references are prior art.

All listed references were cited by, or submitted to, the Office in the parent, co-pending application of the above-identified application. The above-identified application is a divisional of co-pending Application Serial No. 09/388,826, filed September 1, 1999. Such prior disclosure is sufficient for the above-identified application as far as copies of the references are concerned.

Citation of these references is respectfully requested.

Respectfully submitted,

Dated: 3-27-00

Attorney: Mark Matkin

Mark S. Matkin
Reg. No. 32,268

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Form PTO-1449

U.S. DEPARTMENT OF COMMERCE
PATENT AND TRADEMARK OFFICEATTY. DOCKET NO.
MI22-1398SERIAL NO.
09/536,037LIST OF ART CITED BY APPLICANT
(Use several sheets if necessary)

SEP 04 2001

APPLICANT

Weimin (Michael) Li et al.

FILING DATE

March 27, 2000

GROUP

2822

U.S. PATENT DOCUMENTS

Examiner	Document Number	Date	Name	Class	Subclass	Filing Date If Appropriate
	AA 4,474,975	10-2-1984	Clemons et al.			
	AB 5,962,581	10-5-1999	Hayase et al.			
	AC 4,805,683	2-21-1989	Magdo et al.			
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	AE 5,858,880	1-12-1999	Dobson et al.			
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	AG 5,270,267	12-14-1993	Ouellet			
	AH 5,541,445	7-30-1996	Quellet			
	AI 6,022,404	2-8-2000	Ettlinger et al.			
	AJ 5,709,741	1-20-1998	Akamatsu et al.			
	AK 4,648,904	3-10-1987	DePasquale et al.			
	AL 4,158,717	6-19-1979	Nelson			
	AM 5,667,015	9-16-1997	Harestad et al.			
	AN 5,661,093	8-26-1997	Ravi et al.			
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	AP 4,695,859	9-22-1987	Guha et al.			
	AQ 5,061,509	10-29-1991	Naito et al.			
	AR 4,600,671	7-15-1986	Saitoh et al.			
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	AV 5,674,356	10-7-1997	Nagayama			
	AW 5,731,242	3-24-1998	Parat et al.			
	AX 5,741,721	4-21-1998	Stevens			

EXAMINER

DATE CONSIDERED

EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.